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Transmission Electron Microscopy (TEM) is a well-established technique for high-resolution imaging down to atomic scale [1]. However, analyses of low-Z elements (Z < 6) are notoriously difficult or even impossible using the typical analytical tools associated with TEM such as Energy Dispersive X-Ray Spectroscopy or Electron Energy-Loss Spectroscopy. In comparison, Secondary Ion Mass Spectrometry (SIMS) imaging is a well-known high-sensitivity technique for the analysis of all elements of the periodic table including their isotopes [2]. However, the lateral resolution of SIMS imaging is fundamentally limited by the ion-solid interaction volume to ~ 10 nm, which is 2 to 3 orders of magnitude poorer in comparison to TEM imaging. In order to combine the benefits of TEM and SIMS in a single instrument, we developed an in-situ TEM-SIMS technique [3].

The octagon of a FEI Tecnai G2 F20 TEM was adapted to integrate a Focused Ion Beam (FIB) column and an in-house designed and built compact mass spectrometer (Fig. 1). The FIB is a FEI Magnum column with monoisotopic $^{69}$Ga$^+$ source. A special TEM sample holder with a tip that can be biased up to ± 4.5 kV was developed to enhance the collection efficiency of the secondary ions. With this set up, TEM and SIMS images can be obtained within the same instrument, thus decreasing the analysis time. Furthermore, artefacts associated with sample transfer between different stand-alone instruments, such as sample modifications and non-systematic image distortions, etc. are avoided. The correlative TEM-SIMS datasets (e.g. Fig. 2) thus obtained can then be treated by image fusion methods to derive new insights not achieved by the individual techniques [4].

In this presentation, our recent results related to the analysis of low-Z elements in materials science applications will be discussed. A special focus will be on the imaging and analysis of hydrogen (Z=1) (including deuterium), and boron (Z = 5) in silicon solar cells. Additionally, we will also discuss the imaging of lithium (Z=3) and other elements in cathode materials of cycled and uncycled lithium-ion batteries [5].

References:

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Figure 1. The layout (a), photos (b, e) and schematics (c, d) of the in-situ TEM-SIMS instrument (Adapted from [3]).

Figure 2. In-situ SIMS images (H\(^{-}\) and D\(^{-}\)) superposed on a corresponding TEM image from a sample containing a physical mixture KD\(_2\)PO\(_4\) and KH\(_2\)PO\(_4\) powders. Because of the non-UHV conditions in the TEM, the H map has a higher background level than the D map.